

NEWS

NanoMaterials Technology Participates in Japan Nanotech and US Nanotech 2010

Singapore, April 8, 2010 – NanoMaterials Technology Private Limited (“NMT”) participated in the 9th Japan Nanotech 2010 International Nanotechnology Exhibition and Conference in Tokyo, Japan from February 17 to February 19, 2010. The three-day exhibition gathered 42,381 visitors at Tokyo Big. NMT booth was located at the Singapore Pavilion together with International Enterprise (IE) Singapore and other Singapore representative companies. NMT has soft-launched its new product – a series of nano-sized metal oxide dispersion during the exhibition. NMT utilizes its proprietary High Gravity Controlled Precipitation (HGCP) Technology and dispersion technology to produce commercial-scale nano-sized metal oxides such as ZnO, ATO, CeO₂, Fe₃O₄ and TiO₂, which can be mono-dispersed in both water-borne and solvent-borne dispersion media. The dispersion is highly transparent with solid loading up to 50%. The product has various properties such as UV light absorbing, IR light reflecting, anti-abrasion, photo-catalytic, oxygen-storing, abrasive and magnetic heating, which are suitable for performance enhancement to various application such as automotive & wood coatings, solar control film/coating, petrochemicals, CMP, plastics & polymer and medical.

NMT will also be participating in the 13th US Nanotech Conference and Expo 2010 in Anaheim, California from June 21 to 26, 2010. The event will be held at Anaheim Convention Center and expected to attract more than 5,000 attendees and 350 exhibitors. NMT will be showcasing its products and services in both specialty chemicals and pharmaceutical. (Details: <http://www.nanomt.com>)